Anisotropic, non-uniform misfit strain in a thin film bonded on a plate substrate

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Abstract. Current methodologies used for the inference of thin film stresses through curvature measurements are strictly restricted to stress and curvature states which are assumed to remain uniform over the entire film/substrate system. These methodologies have recently been extended to non-uniform stress and curvature states for the thin film subject to non-uniform, isotropic misfit strains. In this paper we study the same thin film/substrate system but subject to non-uniform, anisotropic misfit strains. The film stresses and system curvatures are both obtained in terms of the non-uniform, anisotropic misfit strains. For arbitrarily non-uniform, anisotropic misfit strains, it is shown that a direct relation between film stresses and system curvatures cannot be established. However, such a relation exists for uniform or linear anisotropic misfit strains, or for the average film stresses and average system curvatures when the anisotropic misfit strains are arbitrarily non-uniform.

Keywords: anisotropic film misfit strains and stresses; non-uniform film stresses and system curvatures; stress-curvature relations; non-local effects; interfacial shear.

1. Introduction

Stoney (1909) used a plate system composed of a thin film, of thickness \( h_f \), deposited on a relatively thick substrate, of thickness \( h_s \), and derived a simple relation between the curvature, \( \kappa \), of the system and the stress, \( \sigma^{(f)} \), of the film as follows:

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In the above the subscripts "f" and "s" denote the thin film and substrate, respectively, and $E$ and $v$ are the Young’s modulus and Poisson’s ratio. Eq. (1) is called the Stoney formula, and it has been extensively used in the literature to infer film stress changes from experimental measurement of system curvature changes (Freund and Suresh 2004).

The Stoney formula was derived for an isotropic “thin” solid film of uniform thickness deposited on a much “thicker” plate substrate based on a number of assumptions. The assumptions include the following: (1) Both the film thickness $h_f$ and the substrate thickness $h_s$ are uniform and $h_f << h_s << R$, where $R$ represents the characteristic length in the lateral direction (e.g. system radius $R$ shown in Fig. 1); (2) The strains and rotations of the plate system are infinitesimal; (3) Both the film and substrate are homogeneous, isotropic, and linearly elastic; (4) The film stress states are in-plane equi-biaxial (two equal stress components in any two, mutually orthogonal in-plane directions) while the out-of-plane direct stress and all shear stresses vanish; (5) The system’s curvature components are equi-biaxial (two equal direct curvatures) while the twist curvature vanishes in all directions; and (6) All surviving stress and curvature components are spatially constant over the plate system’s surface, a situation which is often violated in practice.

Despite the explicitly stated assumptions of spatial stress and curvature uniformity, the Stoney formula is often, arbitrarily, applied to cases of practical interest where these assumptions are violated. This is typically done by applying the Stoney formula pointwise and thus extracting a local value of stress from a local measurement of the curvature of the system. This approach of inferring film stresses clearly violates the uniformity assumptions of the analysis and, as such, its accuracy as an
approximation is expected to deteriorate as the levels of curvature non-uniformity become more severe.

Following the initial formulation by Stoney, a number of extensions have been derived by various researchers who have relaxed some of the other assumptions (other than the assumption of uniformity) made by his analysis. Such extensions of the initial formulation include relaxation of the assumption of equi-biaxiality as well as the assumption of small deformations/deflections. A biaxial form of Stoney formula, appropriate for anisotropic film stresses, including different stress values at two different directions and non-zero, in-plane shear stresses, was derived by relaxing the assumption of curvature equi-biaxiality (Freund and Suresh 2004). Related analyses treating discontinuous films in the form of bare periodic lines (Wikstrom et al. 1999a) or composite films with periodic line structures (e.g. bare or encapsulated periodic lines) have also been derived (Shen et al. 1996, Wikstrom et al. 1999b, Park and Suresh 2000). These latter analyses have also removed the assumption of equi-biaxiality and have allowed the existence of three independent curvature and stress components in the form of two, non-equal, direct components and one shear or twist component. However, the uniformity assumption of all of these quantities over the entire plate system was retained. In addition to the above, single, multiple and graded films and substrates have been treated in various “large” deformation analyses (Masters and Salamon 1993, Salamon and Masters 1995 Finot et al. 1997, Freund 2000). These analyses have removed both the restrictions of an equi-biaxial curvature state as well as the assumption of infinitesimal deformations. They have allowed for the prediction of kinematically nonlinear behavior and bifurcations in curvature states. These bifurcations are transformations from an initially equi-biaxial to a subsequently biaxial curvature state that may be induced by an increase in film stresses beyond a critical level. This critical level is intimately related to the system’s aspect ratio, i.e., the ratio of in-plane to thickness dimension and the elastic stiffness. These analyses also retain the assumption of spatial curvature and stress uniformity across the system. However, they allow for deformations to evolve from an initially spherical shape to an energetically favored shape (e.g. ellipsoidal, cylindrical or saddle shapes) which features three different, still spatially constant, curvature components (Lee et al. 2001).

None of the above-discussed extensions of the Stoney methodology have relaxed the most restrictive of Stoney’s original assumption of spatial uniformity which does not allow either film stress or curvature components to vary across the plate surface. This crucial assumption is often violated in practice since film stresses and the associated system curvatures are non-uniformly distributed over the plate area. Huang and Rosakis (2005) and Huang et al. (2005) have recently made progress to remove the two restrictive assumptions of the Stoney analysis relating to spatial uniformity and equi-biaxiality. They have studied the cases of thin film/substrate systems subject to non-uniform but axisymmetric temperature distribution $T(r)$ and misfit strain $\varepsilon_{m}(r)$, respectively. Their results show that the relations between film stresses and system curvatures feature not only a “local part which involves a direct dependence of stresses on curvatures at the same point, but also a “non-local part which reflects of the effect of curvatures at other points on the location of scrutiny. The “non-local” analysis comes into play in the axisymmetric analysis via the average curvature in the thin film. The “non-local” analysis has been extended to general non-uniform temperature (Huang and Rosakis 2007) and misfit strains (Ngo et al. 2006), thin film with non-uniform thickness (Ngo et al. 2007) or different radius from the substrate radius (Feng et al. 2006). The X-ray diffraction and coherent gradient sensing experiments have verified the non-local analysis (Brown et al. 2006, 2007).

The main purpose of the present paper is to extend the non-local analysis for the general case of a thin film/substrate system subject to arbitrary anisotropic misfit strain distribution $\varepsilon_{m}^{(r, \theta)}$. Our goal is to relate film stresses and system curvatures to the misfit strain distribution, and explore a relation between the film stresses and the system curvatures for general anisotropic misfit strain distributions.
2. Governing equations

A thin film of radius \( R \) and thickness \( h_f \) is deposited on a substrate of the same radius and thickness \( h_m \), and \( h_f \ll h_m \ll R \). The Young’s modulus and Poisson’s ratio of the film and substrate are denoted by \( E_f \), \( \nu_f \), \( E_s \) and \( \nu_s \), respectively. The thin film is subject to arbitrary anisotropic and non-uniform misfit strains \( \varepsilon^m_{ij}(r, \theta) \) in the film plane, where \( r \) and \( \theta \) are polar coordinates (Fig. 1).

For convenience we use \( \varepsilon^m_{zz} = \frac{1}{2}(\varepsilon^m_{rr} + \varepsilon^m_{\theta\theta}) = \frac{1}{2}(\varepsilon^m_{xx} + \varepsilon^m_{yy}), \varepsilon^m_\theta = \frac{1}{2}(\varepsilon^m_{rr} - \varepsilon^m_{\theta\theta}) = \frac{1}{2}(\varepsilon^m_{xx} - \varepsilon^m_{yy}) \cos 2\theta + \varepsilon^m_\gamma \sin 2\theta \), and \( \gamma^m = 2\varepsilon^m_\theta \cos 2\theta - (\varepsilon^m_{xx} - \varepsilon^m_{yy}) \sin 2\theta \), where \( x \) and \( y \) are the Cartesian coordinates. For uniform misfit strains \( \varepsilon^m_{xx}, \varepsilon^m_{yy} \), and \( \varepsilon^m_\gamma \) are constants in the Cartesian coordinates (Freund and Suresh 2004), \( \varepsilon^m_z \) is also uniform, but \( \varepsilon^m_\theta \) and \( \gamma^m \) become linear combinations of \( \cos 2\theta \) and \( \sin 2\theta \).

The thin film is modeled as a membrane that has no resistance against bending due to its small thickness \( h_f \ll h_m \). Let \( u_r^{(f)} \) and \( u_\theta^{(f)} \) denote the displacements in the radial (\( r \)) and circumferential (\( \theta \)) directions. The strains in the thin film are \( \varepsilon_{rr} = \frac{\partial u_r^{(f)}}{\partial r}, \varepsilon_{\theta\theta} = \frac{u_\theta^{(f)}}{r} + \frac{1}{r} \frac{\partial u_\theta^{(f)}}{\partial \theta} \), and \( \gamma_{r\theta} = \frac{1}{r} \frac{\partial u_r^{(f)}}{\partial \theta} + \frac{\partial u_\theta^{(f)}}{\partial r} - \frac{u_\theta^{(f)}}{r} \).

The stresses in the thin film can be obtained from the linear elastic constitutive model as

\[
\sigma_{rr} + \sigma_{\theta\theta} = \frac{E_f}{1-\nu_f} \frac{\partial u_r^{(f)}}{\partial r} + \frac{u_r^{(f)}}{r} + \frac{1}{r} \frac{\partial u_\theta^{(f)}}{\partial \theta} - 2\varepsilon^m_z
\]

\[
\sigma_{r\theta} - \sigma_{\theta r} = \frac{E_f}{1+\nu_f} \left( \frac{\partial u_r^{(f)}}{\partial r} - \frac{u_r^{(f)}}{r} - \frac{1}{r} \frac{\partial u_\theta^{(f)}}{\partial \theta} - 2\varepsilon^m_\theta \right)
\]

\[
\sigma_{r\theta} = \frac{E_f}{2(1+\nu_f)} \left( \frac{1}{r} \frac{\partial u_r^{(f)}}{\partial \theta} + \frac{\partial u_\theta^{(f)}}{\partial r} - \frac{u_\theta^{(f)}}{r} - \gamma^m \right)
\]

The membrane forces in the thin film are \( N_r^{(f)} = h_f \sigma_{rr}, N_\theta^{(f)} = h_f \sigma_{\theta\theta}, \) and \( N_{r\theta}^{(f)} = h_f \sigma_{r\theta} \).

For non-uniform misfit strains distribution, the normal stress traction \( \sigma_{zz} \) still vanishes, but the shear stresses \( \sigma_{rz} \) and \( \sigma_{\theta z} \) at the interface do not vanish anymore, and are denoted by \( \tau_r \) and \( \tau_\theta \) respectively. The equilibrium equations for the thin film, accounting for the effect of interface shear stresses \( \tau_r \) and \( \tau_\theta \), become

\[
\frac{\partial N_r^{(f)}}{\partial r} - \frac{N_\theta^{(f)}}{r} + \frac{1}{r} \frac{\partial N_{r\theta}^{(f)}}{\partial \theta} - \tau_r = 0
\]

\[
\frac{\partial N_\theta^{(f)}}{\partial r} + 2N_r^{(f)} + \frac{1}{r} \frac{\partial N_{r\theta}^{(f)}}{\partial \theta} - \tau_\theta = 0
\]

The substitution of Eq. (2) into (3) yields the following governing equations for \( u_r^{(f)}, u_\theta^{(f)}, \tau_r \) and \( \tau_\theta \)

\[
\frac{\partial^2 u_r^{(f)}}{\partial r^2} + \frac{1}{r} \frac{\partial u_r^{(f)}}{\partial r} - \frac{u_r^{(f)}}{r^2} + \frac{1-v_f}{2} \frac{\partial^2 u_\theta^{(f)}}{\partial \theta^2} + \frac{1}{r} \frac{\partial u_\theta^{(f)}}{\partial r} - \frac{3-v_f}{2} \frac{\partial^2 u_\theta^{(f)}}{\partial \theta^2}
\]

\[
= \frac{1-v_f}{E_f h_f} \tau_r + \left[ \frac{1}{(1+v_f)} \frac{\partial \varepsilon^m_z}{\partial r} + \frac{1}{(1-v_f)} \frac{\partial \varepsilon^m_\theta}{\partial r} + \frac{1}{(1-v_f)} \frac{\partial \gamma^m}{\partial r} + \frac{1}{(1-v_f)} \frac{\partial \gamma^m}{\partial \theta} \right]
\]
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\[ \frac{1 + v_f}{2} \frac{\partial^2 u_r^{(f)}}{\partial r^2} - \frac{v_f}{2} \frac{\partial^2 u_r^{(f)}}{\partial r \partial \theta} + \frac{1 - v_f}{2} \left( \frac{\partial^2 u_\theta^{(f)}}{\partial r^2} + \frac{1}{r} \frac{\partial u_\theta^{(f)}}{\partial r} - \frac{u_\theta^{(f)}}{r^2} \right) + \frac{1}{r^2} \frac{\partial^2 u_\theta^{(f)}}{\partial \theta^2} = \frac{1 - v_f^2}{E_f h_f} \left[ (1 + v_f) \frac{1}{r} \frac{\partial^2 w^{(m)}}{\partial \theta^2} - (1 - v_f) \frac{1}{r} \frac{\partial^2 w^{(m)}}{\partial r \partial \theta} + \frac{1 - v_f}{2} \frac{\partial u_\theta^{(m)}}{\partial r} + (1 - v_f) \frac{u_\theta^{(m)}}{r} \right] \quad (4b) \]

Let \( u_r^{(f)} \) and \( u_\theta^{(f)} \) denote the displacements in the radial \((r)\) and circumferential \((\theta)\) directions at the neutral axis \((z = 0)\) of the substrate, and \( w \) the displacement in the normal \((z)\) direction. It is important to consider \( w \) since the substrate can be subject to bending and is modeled as a plate. The strains in the substrate are given by \( \varepsilon_r = \frac{\partial u_r^{(f)}}{\partial r} - \frac{v_f}{r} \frac{\partial u_\theta^{(f)}}{\partial \theta}, \varepsilon_{\theta \theta} = \frac{u_\theta^{(f)}}{r} + \frac{1}{r} \frac{\partial u_\theta^{(f)}}{\partial r} - \frac{1}{r} \frac{\partial w^{(m)}}{\partial r} + \frac{1}{r^2} \frac{\partial^2 w^{(m)}}{\partial r \partial \theta} \), and \( \gamma_{\theta r} = \frac{1}{r} \frac{\partial u_r^{(f)}}{\partial \theta} + \frac{1}{r} \frac{\partial u_\theta^{(f)}}{\partial r} - \frac{2}{r^2} \frac{\partial w^{(m)}}{\partial r} \). The stresses in the substrate can then be obtained from the linear elastic constitutive model as

\[ \sigma_r = E_s \frac{1}{1 - v_s^2} \left[ \frac{\partial u_r^{(f)}}{\partial r} + v_s \left( \frac{u_r^{(f)}}{r} + \frac{1}{r} \frac{\partial u_\theta^{(f)}}{\partial r} \right) - \frac{1}{r} \frac{\partial w^{(m)}}{\partial r} \right] \]
\[ \sigma_{\theta \theta} = E_s \frac{1}{1 - v_s^2} \left[ v_s \frac{\partial u_r^{(f)}}{\partial r} + \frac{u_r^{(f)}}{r} + \frac{1}{r} \frac{\partial u_\theta^{(f)}}{\partial r} - \frac{1}{r} \frac{\partial w^{(m)}}{\partial r} \right] \]
\[ \sigma_{\theta r} = E_s \frac{1}{2(1 + v_s)} \left[ \frac{1}{r} \frac{\partial u_r^{(f)}}{\partial \theta} + \frac{u_\theta^{(f)}}{r} - \frac{2}{r^2} \frac{\partial w^{(m)}}{\partial r} - \frac{2}{r^2} \frac{\partial w^{(m)}}{\partial \theta} \right] \]

The forces in the substrate are obtained by averaging the stresses over the thickness as \( N_r = \frac{E_s h_s}{1 - v_s} \frac{\partial u_r^{(f)}}{\partial r} + v_s \frac{u_r^{(f)}}{r} + \frac{1}{r} \frac{\partial u_\theta^{(f)}}{\partial r} \), \( N_\theta = \frac{E_s h_s}{1 - v_s} v_s \frac{\partial u_r^{(f)}}{\partial r} + \frac{u_r^{(f)}}{r} + \frac{1}{r} \frac{\partial u_\theta^{(f)}}{\partial r} \), and \( N_{\theta r} = \frac{E_s h_s}{2(1 + v_s)} \frac{1}{r} \frac{\partial u_r^{(f)}}{\partial \theta} + \frac{u_\theta^{(f)}}{r} - \frac{2}{r^2} \frac{\partial w^{(m)}}{\partial r} - \frac{2}{r^2} \frac{\partial w^{(m)}}{\partial \theta} \).

The moments in the substrate are obtained from \( -\int_{-h/2}^{h/2} \sigma_r dZ \) as \( M_r = \frac{E_s h_s^3}{12(1 - v_s)} \left[ \frac{\partial w^{(m)}}{\partial r^2} + \frac{1}{r} \frac{\partial w^{(m)}}{\partial r} + \frac{1}{r^2} \frac{\partial w^{(m)}}{\partial \theta} \right] \), and \( M_\theta = \frac{E_s h_s^3}{12(1 + v_s)} \frac{\partial}{\partial \theta} \left( \frac{1}{r} \frac{\partial w^{(m)}}{\partial r} \right) \).

The shear stresses \( \tau_r \) and \( \tau_\theta \) at the thin film/substrate interface are equivalent to the distributed forces \( \tau_r \) in the radial direction and \( \tau_\theta \) in the circumferential direction, and bending moments \( h_s / 2 \tau_r \) and \( h_s / 2 \tau_\theta \) applied at the neutral axis \((z = 0)\) of the substrate. The in-plane force equilibrium equations of the substrate then become

\[ \frac{\partial N_r^{(f)}}{\partial r} + \frac{N_r^{(f)}}{r} + \frac{1}{r} \frac{\partial N_\theta^{(f)}}{\partial \theta} + \tau_r = 0 \]
\[ \frac{N_r^{(f)}}{r} + \frac{1}{r} \frac{\partial N_\theta^{(f)}}{\partial \theta} + \tau_\theta = 0 \]

(6)
The substitution of \( N_r^{(1)} \), \( N_{\theta}^{(1)} \), and \( \tilde{N}_{\theta}^{(1)} \) in terms of the displacements into the above equation yields the following governing equations for \( u_r^{(1)}, u_{\theta}^{(1)}, \tau_r \), and \( \tau_{\theta} \)

\[
\frac{\partial^2 u_r^{(1)}}{\partial r^2} + \frac{1}{r} \frac{\partial u_r^{(1)}}{\partial r} - \frac{u_r^{(1)}}{r^2} + \frac{1+v}{2} \frac{1}{r^2} \frac{\partial^2 u_r^{(1)}}{\partial \theta^2} + \frac{1+v}{2} \frac{1}{r^2} \frac{\partial^2 u_{\theta}^{(1)}}{\partial r \partial \theta} - \frac{3-v}{2} \frac{1}{r^2} \frac{\partial u_{\theta}^{(1)}}{\partial \theta} = -\frac{1-v^2}{E_s h_s} \tau_r
\]  

(7a)

\[
\frac{1+v}{2} \frac{1}{r} \frac{\partial u_r^{(1)}}{\partial \theta} + \frac{3-v}{2} \frac{1}{r^2} \frac{\partial u_{\theta}^{(1)}}{\partial \theta} + \frac{1-v}{2} \left( \frac{\partial^2 u_{\theta}^{(1)}}{\partial r^2} + \frac{1}{r} \frac{\partial u_{\theta}^{(1)}}{\partial r} - \frac{u_{\theta}^{(1)}}{r^2} \right) + \frac{1}{r^2} \frac{\partial^2 u_{\theta}^{(1)}}{\partial \theta^2} = -\frac{1-v^2}{E_s h_s} \tau_{\theta}
\]  

(7b)

The out-of-plane moment and force equilibrium equations are given by

\[
\frac{\partial M_r}{\partial r} + \frac{M_r - M_0}{r} + \frac{1}{r} \frac{\partial M_{\theta}}{\partial \theta} + Q_r \frac{h_s}{2} = 0
\]  

(8)

\[
\frac{\partial M_{\theta}}{\partial r} + \frac{2}{r} \frac{M_0}{r} + \frac{1}{r} \frac{\partial M_{\theta}}{\partial \theta} + Q_\theta \frac{h_s}{2} = 0
\]  

(9)

where \( Q_r \) and \( Q_\theta \) are the shear forces normal to the neutral axis. Elimination of \( Q_r \) and \( Q_\theta \) from the above two equations in conjunction with the moments-displacement relation, give the following governing equations for \( w, \tau_r \) and \( \tau_{\theta} \)

\[
\nabla^2 (\nabla^2 w) = \frac{6(1-v^2)}{E_s h_s} \left( \frac{\partial \tau_r}{\partial r} + \frac{\partial \tau_{\theta}}{\partial \theta} \right)
\]  

(10)

where

\[
\nabla^2 = \frac{\partial^2}{\partial r^2} + \frac{1}{r} \frac{\partial}{\partial r} + \frac{1}{r^2} \frac{\partial^2}{\partial \theta^2}
\]

The continuity of displacements across the thin film/substrate interface requires

\[
u_r^{(1)} = u_r^{(h)} - \frac{h_s}{2} \frac{\partial w}{\partial r}, \quad u_{\theta}^{(1)} = u_{\theta}^{(h)} - \frac{h_s}{2} \frac{\partial w}{\partial \theta}
\]  

(11)

Eqs. (4), (7), (10) and (11) constitute seven ordinary differential equations for \( u_r^{(1)}, u_{\theta}^{(1)}, u_r^{(h)}, u_{\theta}^{(h)}, w, \tau_r \) and \( \tau_{\theta} \). Under the limit \( h_s << h_t \), these seven equations can be decoupled to solve \( u_r^{(1)}, u_{\theta}^{(1)}, u_r^{(h)}, u_{\theta}^{(h)} \) first, followed by \( w, \tau_r \) and \( \tau_{\theta} \), and finally \( \tau_r \) and \( \tau_{\theta} \) as discussed in the following.

(i) Elimination of \( \tau_r \) and \( \tau_{\theta} \) from Eqs. (4) and (7) yields two equations for \( u_r^{(1)}, u_{\theta}^{(1)}, u_r^{(h)}, u_{\theta}^{(h)}, \) and \( u_r^{(1)} \).

For \( h_s << h_t \), \( u_r^{(1)} \) and \( u_{\theta}^{(1)} \) disappear in these two equations which give the following governing equations for \( u_r^{(1)} \) and \( u_{\theta}^{(1)} \) only,

\[
\frac{\partial^2 u_r^{(1)}}{\partial r^2} + \frac{1}{r} \frac{\partial u_r^{(1)}}{\partial r} - \frac{u_r^{(1)}}{r^2} + \frac{1+v}{2} \frac{1}{r^2} \frac{\partial^2 u_r^{(1)}}{\partial \theta^2} + \frac{1+v}{2} \frac{1}{r^2} \frac{\partial^2 u_{\theta}^{(1)}}{\partial r \partial \theta} - \frac{3-v}{2} \frac{1}{r^2} \frac{\partial u_{\theta}^{(1)}}{\partial \theta} = -\frac{1-v^2}{E_s h_s} \tau_r
\]  

(12a)

\[
\frac{1+v}{2} \frac{1}{r} \frac{\partial u_r^{(1)}}{\partial \theta} + \frac{3-v}{2} \frac{1}{r^2} \frac{\partial u_{\theta}^{(1)}}{\partial \theta} + \frac{1-v}{2} \left( \frac{\partial^2 u_{\theta}^{(1)}}{\partial r^2} + \frac{1}{r} \frac{\partial u_{\theta}^{(1)}}{\partial r} - \frac{u_{\theta}^{(1)}}{r^2} \right) + \frac{1}{r^2} \frac{\partial^2 u_{\theta}^{(1)}}{\partial \theta^2} = -\frac{1-v^2}{E_s h_s} \tau_{\theta}
\]
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\[ \frac{E_t h_t}{1-v_f^2} \left[ (1+v_f) \frac{1}{r} \frac{\partial \varepsilon_{m}^{\theta}}{\partial \theta} - (1-v_f) \frac{1}{r} \frac{\partial \varepsilon_{m}^{\theta}}{\partial r} + \frac{1}{2} \frac{1}{r^2} \frac{\partial w}{\partial r} \right] \]

(ii) Elimination of \( u_r^{(t)} \) and \( u_\theta^{(t)} \) from Eqs. (4) and (11) gives \( \tau_r \) and \( \tau_\theta \) in terms of \( u_r^{(o)} \), \( u_\theta^{(o)} \) and \( w \) (and \( \varepsilon_{c}^{m}, \varepsilon_{\lambda}^{m}, \gamma_{r}^{m} \)).

(iii) The substitution of \( \tau_r \) and \( \tau_\theta \) in (ii) into Eq. (10) yields the following governing equation for the normal displacement \( w \): For \( h_f << h_t \), the governing equation becomes

\[
\nabla^2 (\nabla^2 w) = -6 \frac{E_t h_t}{1-v_f^2} \left[ (1+v_f) \frac{1}{r} \frac{\partial \varepsilon_{m}^{\theta}}{\partial \theta} - (1-v_f) \frac{1}{r} \frac{\partial \varepsilon_{m}^{\theta}}{\partial r} + \frac{1}{2} \frac{1}{r^2} \frac{\partial w}{\partial r} \right] \]

\[
+ (1-v_f) \left[ \frac{\partial^2 \varepsilon_{m}^{\theta}}{\partial r^2} + \frac{\partial \varepsilon_{m}^{\theta}}{\partial r} + \frac{1}{2} \frac{\partial^2 \varepsilon_{m}^{\theta}}{\partial r^2} \right] \]

\[
+ (1-v_f) \left[ \frac{\partial^2 \gamma_{r}^{m}}{r \partial \theta^2} + \frac{\partial \gamma_{r}^{m}}{r \partial \theta} \right]
\]

This biharmonic equation can be solved analytically, which gives the substrate displacement \( w \).

(iv) The displacements \( u_r^{(t)} \) and \( u_\theta^{(t)} \) are obtained from Eq. (11). The leading terms of the interface shear stresses \( \tau_r \) and \( \tau_\theta \) are then obtained from Eq. (4) as

\[
\tau_r = - \frac{E_t h_t}{1-v_f^2} \left[ (1+v_f) \frac{1}{r} \frac{\partial \varepsilon_{m}^{\theta}}{\partial \theta} - (1-v_f) \frac{1}{r} \frac{\partial \varepsilon_{m}^{\theta}}{\partial r} + \frac{1}{2} \frac{1}{r^2} \frac{\partial w}{\partial r} \right] \]

\[
\tau_\theta = \frac{E_t h_t}{1-v_f^2} \left[ (1+v_f) \frac{1}{r} \frac{\partial \varepsilon_{m}^{\theta}}{\partial \theta} + \frac{1}{2} \frac{1}{r^2} \frac{\partial w}{\partial r} \right]
\]

These are remarkable results that hold regardless of boundary conditions at the edge \( r = R \). Therefore the interface shear stresses are proportional to the gradients of misfit strains. For uniform misfit strain \( \varepsilon_{c}^{m}, \varepsilon_{\lambda}^{m}, \gamma_{r}^{m} \), and \( \varepsilon_{c}^{m} \)-constants in the Cartesian coordinates (Freund and Suresh 2004), the interface shear stresses do NOT vanish unless \( \varepsilon_{c}^{m} = \varepsilon_{\lambda}^{m} \)-constant and \( \varepsilon_{c}^{m} = 0 \) (i.e. the isotropic Stoney formula).

We expand the arbitrary non-uniform misfit strain distributions \( \varepsilon_{c}^{m}(r, \theta), \varepsilon_{\lambda}^{m}(r, \theta) \) and \( \gamma_{r}^{m}(r, \theta) \) to the Fourier series in order to solve the above partial differential equations. Analytically

\[
\varepsilon_{c}^{m}(r, \theta) = \sum_{n=0}^{\infty} \sum_{n=1}^{\infty} \varepsilon_{c}^{m(n)}(r) \cos n \theta + \varepsilon_{c}^{m(n)}(r) \sin n \theta
\]

\[
\varepsilon_{\lambda}^{m}(r, \theta) = \sum_{n=0}^{\infty} \varepsilon_{\lambda}^{m(n)}(r) \cos n \theta + \varepsilon_{\lambda}^{m(n)}(r) \sin n \theta
\]

\[
\gamma_{r}^{m}(r, \theta) = \sum_{n=0}^{\infty} \gamma_{r}^{m(n)}(r) \cos n \theta + \gamma_{r}^{m(n)}(r) \sin n \theta
\]

where \( \varepsilon_{c}^{m(0)}(r) = \frac{2\pi}{2} \int_{0}^{2\pi} \varepsilon_{c}^{m}(r, \theta) d\theta, \varepsilon_{c}^{m(n)}(r) = \frac{2\pi}{2} \int_{0}^{2\pi} \varepsilon_{c}^{m(n)}(r, \theta) d\theta, \gamma_{c}^{m(0)}(r) = \frac{2\pi}{2} \int_{0}^{2\pi} \gamma_{c}^{m(0)}(r, \theta) d\theta, \varepsilon_{c}^{m(n)}(r) = \)
\( \frac{1}{2\pi} \psi_{2\varepsilon}(r, \theta) \cos \theta d\theta, \psi_{2\varepsilon}(r, \theta) \cos \theta d\theta, \gamma_c^{(m)}(r) = \frac{1}{2\pi} \gamma_m(r, \theta) \cos \theta d\theta (n \geq 1), \)

\( \psi_{2\varepsilon}(r, \theta) \sin \theta d\theta, \psi_{2\varepsilon}(r, \theta) \sin \theta d\theta, \gamma_s^{(m)}(r) = \frac{1}{2\pi} \gamma_m(r, \theta) \sin \theta d\theta \)

\( (n \geq 1) \).

Without losing generality, we focus on the \( \cos n\theta \) term in \( \psi_{2\varepsilon}(r, \theta) \) and \( \psi_s^{(m)}(r, \theta) \) and \( \sin n\theta \) term in \( \gamma_m(r, \theta) \) in the following. The corresponding displacements and interface shear stresses can be expressed as

\[ u_r^{(m)} = u_r^{(m)}(r) \cos \theta, u_\theta^{(m)} = u_\theta^{(m)}(r) \sin \theta, w = w^{(m)}(r) \cos \theta \]  

Eq. (12) then gives two ordinary differential equations for \( u_r^{(m)} \) and \( u_\theta^{(m)} \), which have the general solution

\[
\begin{align*}
   u_r^{(m)} &= \frac{1}{8}\frac{E_s h_s}{1 - \nu^2} + \nu \frac{E_s h_s}{1 - \nu^2} \\
   &+ (1 - \nu_r^{(m)}(1 + \nu)) \left[ \frac{4(1 + \nu)(1 - \nu)}{2} \int_0^{\pi^2} \left[ \eta^{n-1} e_c^{(m)}(\eta) \eta + \eta^{n-1} e_s^{(m)}(\eta) \eta \right] d\eta \\
   &+ (1 - \nu_r^{(m)}(1 + \nu)) \left[ \frac{4(1 + \nu)(1 - \nu)}{2} \int_0^{\pi^2} \left[ \eta^{n-1} e_c^{(m)}(\eta) \eta + \eta^{n-1} e_s^{(m)}(\eta) \eta \right] d\eta \\
   &- (1 - \nu_r^{(m)}(1 + \nu)) \left[ \frac{4(1 + \nu)(1 - \nu)}{2} \int_0^{\pi^2} \left[ \eta^{n-1} e_c^{(m)}(\eta) \eta + \eta^{n-1} e_s^{(m)}(\eta) \eta \right] d\eta \right] \right] \\
   &+ \left(1 - \frac{1}{2} \nu - \frac{1}{2} \nu \right) A_\theta r^{1+n} - D_\theta r^{n-1} \\
\end{align*}
\]  

\[
\begin{align*}
   u_\theta^{(m)} &= \frac{1}{8}\frac{E_s h_s}{1 - \nu^2} + \nu \frac{E_s h_s}{1 - \nu^2} \\
   &+ (1 - \nu_r^{(m)}(1 + \nu)) \left[ \frac{4(1 + \nu)(1 - \nu)}{2} \int_0^{\pi^2} \left[ \eta^{n-1} e_c^{(m)}(\eta) \eta + \eta^{n-1} e_s^{(m)}(\eta) \eta \right] d\eta \\
   &+ (1 - \nu_r^{(m)}(1 + \nu)) \left[ \frac{4(1 + \nu)(1 - \nu)}{2} \int_0^{\pi^2} \left[ \eta^{n-1} e_c^{(m)}(\eta) \eta + \eta^{n-1} e_s^{(m)}(\eta) \eta \right] d\eta \\
   &- (1 - \nu_r^{(m)}(1 + \nu)) \left[ \frac{4(1 + \nu)(1 - \nu)}{2} \int_0^{\pi^2} \left[ \eta^{n-1} e_c^{(m)}(\eta) \eta + \eta^{n-1} e_s^{(m)}(\eta) \eta \right] d\eta \right] \right] \\
   &+ \left(1 + \frac{1}{2} \nu + 2 \right) \left( A_\theta r^{1+n} + D_\theta r^{n-1} \right) \\
\end{align*}
\]
where $A_0$ and $D_0$ are constants to be determined, and the condition of finite displacements at the center $r = 0$ has been used.

The normal displacement is obtained from the biharmonic Eq. (13) as

$$w^{(m)}_n = \frac{3E Rh_1}{4(1-v^2)} \left[ \frac{1}{1+v} \left[ \frac{4(1+v)(1-v^2)R^{2n+1} \left\{ \eta^{1+n} \frac{\Delta \epsilon_s}{\Delta \epsilon_s} \right\}}{1+v} \right] \right]$$

under the limit $h_f < h_s$. The other two boundary conditions at the free edge $r = R$ are the vanishing of net moments, i.e.,

\[ \text{Section 3. Boundary conditions} \]

The first two boundary conditions at the free edge $r = R$ require that the net forces vanish,

$$N_{r}^{(f)} + N_{r}^{(e)} = 0 \quad \text{and} \quad M_{r}^{(f)} + M_{r}^{(e)} = 0 \quad \text{at} \quad r = R$$

which give $A_0$ and $D_0$ as

$$A_0 = \frac{1}{4(1-v^2)} \left[ \frac{1}{1+v} \left[ \frac{4(1+v)(1-v^2)R^{2n+1} \left\{ \eta^{1+n} \frac{\Delta \epsilon_s}{\Delta \epsilon_s} \right\}}{1+v} \right] \right]$$

(18)
which give $A_1$ and $B_1$ as

$$
A_1 = \frac{3E_h}{4(1-v_2^2)} h_n \left[ 4(1+v_2)R^{2(n+1)} \left[ \eta^{1+n} \int_0^\infty \frac{\varepsilon_{\varphi\varphi}}{\varepsilon_{\varphi\varphi}} \, d\eta \right] \right]$$

and

$$
B_1 = \frac{3E_h}{4(1-v_2^2)} h_n \left[ 4(1+v_2)R^{2n} \left[ \eta^n \int_0^\infty \frac{\varepsilon_{\varphi\varphi}}{\varepsilon_{\varphi\varphi}} \, d\eta \right] \right]$$

The thin-film stresses and system curvatures are

$$
\kappa_{rr} = \frac{\partial^2 W}{\partial r^2}, \quad \kappa_{\theta\theta} = \frac{1}{r} \frac{\partial W}{\partial r} + \frac{1}{r^2} \frac{\partial^2 W}{\partial \theta^2} + \kappa_{\varphi\varphi} = \frac{1}{r} \frac{\partial^2 W}{\partial r \partial \theta}.
$$

The sum of system curvatures is related to the misfit strains by

$$
\kappa_{rr} + \kappa_{\theta\theta} = -3 \frac{E_h}{1-v_2^2} h_n \left[ 2(1+v_2) \varepsilon_{\varphi\varphi}^m + 2(1-v_2) \varepsilon_{\varphi\varphi}^m + 4(1+v_2) \left[ \eta^{1+n} \int_0^\infty \frac{\varepsilon_{\varphi\varphi}}{\varepsilon_{\varphi\varphi}} \, d\eta + (1+v_2) \frac{1-v_2}{1+v_2} R \int_0^\infty \frac{\varepsilon_{\varphi\varphi}}{\varepsilon_{\varphi\varphi}} \, d\eta \right] \right]
$$

and

$$
\kappa_{rr} + \kappa_{\theta\theta} = -3 \frac{E_h}{1-v_2^2} h_n \left[ \sum_{n=1}^\infty (n+1) \left( \cos \theta \frac{r^{n+1}}{\eta^{n+1}} (2 \varepsilon_{\varphi\varphi}^m + \varepsilon_{\varphi\varphi}^m) + \sin \theta \frac{r^{n+1}}{\eta^{n+1}} (2 \varepsilon_{\varphi\varphi}^m + \varepsilon_{\varphi\varphi}^m) \right) \right]
$$

4. Thin-film stresses and system curvatures

We provide the general solution that includes both cosine and sine terms in this section. The system curvatures are

$$
\kappa_{rr} = \frac{\partial^2 W}{\partial r^2}, \quad \kappa_{\theta\theta} = \frac{1}{r} \frac{\partial W}{\partial r} + \frac{1}{r^2} \frac{\partial^2 W}{\partial \theta^2}, \quad \kappa_{\varphi\varphi} = \frac{1}{r} \frac{\partial^2 W}{\partial r \partial \theta}.
$$

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\[ -3 \frac{E_i h_i}{1 - v_i} \frac{1 - v_f}{1 - v_f E_s h_s^2 + v_s} \]

\[
\begin{align*}
-3 \frac{E_i h_i}{1 - v_i} & \frac{1 - v_f}{1 - v_f E_s h_s^2 + v_s} \\
& \left\{ 4 \left(1 + v_f \right) \sum_{n=1}^{\infty} (n + 1) r^n \frac{R^n}{n^{n+1}} \left[ \cos \frac{\theta}{\eta} \eta^{n+1} \varepsilon_{\Sigma C}^{m(n)} d \eta + \sin \frac{\theta}{\eta} \eta^{n+1} \varepsilon_{\Sigma C}^{m(n)} d \eta \right] \\
& \left. \right\} \sum_{n=1}^{\infty} (n - 1) \frac{r^n}{n^{2n}} \left[ \cos \frac{\theta}{\eta} \eta^{n-1} (2 \varepsilon_{\Sigma C}^{m(n)} - \gamma_s^{m(n)}) d \eta + \sin \frac{\theta}{\eta} \eta^{n-1} (2 \varepsilon_{\Sigma C}^{m(n)} + \gamma_s^{m(n)}) d \eta \right] \\
& \left. \right\} \sum_{n=1}^{\infty} n (n + 1) \frac{r^n}{n^{2(n+1)}} \left[ \cos \frac{\theta}{\eta} \eta^{n+1} (2 \varepsilon_{\Sigma C}^{m(n)} - \gamma_s^{m(n)}) d \eta + \sin \frac{\theta}{\eta} \eta^{n+1} (2 \varepsilon_{\Sigma C}^{m(n)} + \gamma_s^{m(n)}) d \eta \right] \\
& \left. \right\}
\end{align*}
\]

(24)

The average curvature sum over the entire thin film \( \overline{\kappa_r + \kappa_{00}} = \frac{1}{\pi R} \int d\theta \frac{R}{\theta} (\kappa_r + \kappa_{00}) d\eta \) is then obtained as

\[
\overline{\kappa_r + \kappa_{00}} = -12 \frac{E_i h_i}{1 - v_i} \frac{1 - v_f}{1 - v_f E_s h_s^2 + v_s} \overline{\varepsilon_C} \]

(25)

where \( \overline{\varepsilon_C} = \frac{1}{\pi R} \int d\theta \frac{R}{\theta} \overline{\varepsilon_C^{m(n)}} d\eta \) is the average misfit strain sum. The subtraction of the average curvature sum from Eq. (24) gives

\[ \kappa_{00} - \overline{\kappa_r} = -3 \frac{E_i h_i}{1 - v_i} \frac{1 - v_f}{1 - v_f E_s h_s^2 + v_s} \]

\[ 2 \left(1 + v_f \right) \left( \overline{\varepsilon_C^{m(n)}} - \overline{\varepsilon_C^{m(n)^0}} \right) + 2 \left(1 - v_f \right) \varepsilon_{\Sigma C}^{m(n)} + 4 \left(1 - v_f \right) \left[ \eta^{n+1} \varepsilon_{\Sigma C}^{m(n)} d \eta \right] \\
\left\{ \cos \frac{\theta}{\eta} \eta^{n+1} (2 \varepsilon_{\Sigma C}^{m(n)} + \gamma_s^{m(n)}) d \eta + \sin \frac{\theta}{\eta} \eta^{n+1} (2 \varepsilon_{\Sigma C}^{m(n)} - \gamma_s^{m(n)}) d \eta \right\} \\
\left. \right\} \sum_{n=1}^{\infty} (n - 1) \frac{r^n}{n^{2n}} \left[ \cos \frac{\theta}{\eta} \eta^{n-1} (2 \varepsilon_{\Sigma C}^{m(n)} - \gamma_s^{m(n)}) d \eta + \sin \frac{\theta}{\eta} \eta^{n-1} (2 \varepsilon_{\Sigma C}^{m(n)} + \gamma_s^{m(n)}) d \eta \right] \\
\left. \right\} \sum_{n=1}^{\infty} n (n + 1) \frac{r^n}{n^{2(n+1)}} \left[ \cos \frac{\theta}{\eta} \eta^{n+1} (2 \varepsilon_{\Sigma C}^{m(n)} - \gamma_s^{m(n)}) d \eta + \sin \frac{\theta}{\eta} \eta^{n+1} (2 \varepsilon_{\Sigma C}^{m(n)} + \gamma_s^{m(n)}) d \eta \right] \\
-3 \frac{E_i h_i}{1 - v_i} \frac{1 - v_f}{1 - v_f E_s h_s^2 + v_s} \]
The difference between two curvatures, \( \kappa_r - \kappa_{\theta \theta} \), and the twist \( \kappa_{r \theta} \) are given by

\[
\kappa_{r \theta} = \frac{3}{4} E_f h_f \frac{1 - v_f^2}{2 - v_f^2 E_s h_s^2}
\]

\[
4(1 + v_f) \sum_{n=1}^{\infty} (n + 1) \frac{r^n}{R^{3(n+1)}} \left[ \cos \theta \left[ \frac{R}{\eta} \right]^{n+1} \frac{m(\eta)}{\varepsilon_{2x}} \, d\eta + \sin \theta \left[ \frac{R}{\eta} \right]^{n+1} \frac{m(\eta)}{\varepsilon_{2x}} \, d\eta \right]
\]

\[
- (1 - v_f) \sum_{n=1}^{\infty} (n^2 - 1) \frac{r^n}{R^n} \left[ \cos \theta \left[ \frac{R}{\eta} \right]^{n-1} (2 \varepsilon_{2x} - \kappa_{r \theta}^n) \, d\eta + \sin \theta \left[ \frac{R}{\eta} \right]^{n-1} (2 \varepsilon_{2x} + \kappa_{r \theta}^n) \, d\eta \right]
\]

\[
+ (1 - v_f) \sum_{n=1}^{\infty} n(n + 1) \frac{r^n}{R^{2(n+1)}} \left[ \cos \theta \left[ \frac{R}{\eta} \right]^{n+1} (2 \varepsilon_{2x} - \kappa_{r \theta}^n) \, d\eta + \sin \theta \left[ \frac{R}{\eta} \right]^{n+1} (2 \varepsilon_{2x} + \kappa_{r \theta}^n) \, d\eta \right]
\]

(26)

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\[
\kappa_{r\theta} = \frac{3 E_s h_s^{-1} v_s^2}{4(1 - v_s) E_s h_s^2}
\]

\[
4(1 + v_s) \sum_{n=1}^{\infty} (n - 1) n^{2(n+1)} \left[ \sin \theta \frac{R}{0} \eta^{n+1} \epsilon_{r\theta}^{m(n)} d\eta - \cos \theta \frac{R}{0} \eta^{n+1} \epsilon_{r\theta}^{m(n)} d\eta \right]
\]

\[
+ 4(1 + v_s) \sum_{n=1}^{\infty} (n + 1) n^{2(n+1)} \left[ \sin \theta \frac{R}{0} \eta^{n+1} \epsilon_{r\theta}^{m(n)} d\eta - \cos \theta \frac{R}{0} \eta^{n+1} \epsilon_{r\theta}^{m(n)} d\eta \right]
\]

\[
+ (1 - v_s) \sum_{n=1}^{\infty} n(n+1) n^{2(n+1)} \left[ \sin \theta \frac{R}{0} \eta^{n+1} (2 \epsilon_{r\theta}^{m(n)} + \gamma_s^{m(n)}) d\eta - \cos \theta \frac{R}{0} \eta^{n+1} (2 \epsilon_{r\theta}^{m(n)} + \gamma_s^{m(n)}) d\eta \right]
\]

\[
- (1 - v_s) \sum_{n=1}^{\infty} n(n+1) n^{2(n+1)} \left[ \sin \theta \frac{R}{0} \eta^{n+1} (2 \epsilon_{r\theta}^{m(n)} - \gamma_s^{m(n)}) d\eta - \cos \theta \frac{R}{0} \eta^{n+1} (2 \epsilon_{r\theta}^{m(n)} - \gamma_s^{m(n)}) d\eta \right]
\]

\[
(27)
\]
The difference between stresses, $\sigma_{rr}^{(f)} - \sigma_{\theta\theta}^{(f)}$, and shear stress $\sigma_{r\theta}^{(f)}$ are given by

$$\sigma_{rr}^{(f)} - \sigma_{\theta\theta}^{(f)} = \frac{E_f}{1 + v_f} (-2 \hat{\varepsilon}^m) \quad (30)$$

$$\sigma_{r\theta}^{(f)} = \frac{E_f}{2(1 + v_f)} (-\hat{\gamma}) \quad (31)$$

5. Limiting cases

We present a few limit cases to further illustrate the thin film stresses and system curvatures in Section 4.
5.1 Uniform misfit strains in the Cartesian coordinates

Freund and Suresh (2004) obtained the solution for arbitrarily anisotropic but uniform misfit strains in the Cartesian coordinates, \( \varepsilon_{xx}^m, \varepsilon_{yy}^m \) and \( \gamma_{xy}^m \) constants. For this case \( \varepsilon_\Sigma^m = \frac{1}{2} (\varepsilon_{xx}^m + \varepsilon_{yy}^m) \) is a constant, but \( \varepsilon_\Sigma^A = \frac{1}{2} (\varepsilon_{xx}^m - \varepsilon_{yy}^m) \cos 2\theta + \frac{1}{2} \gamma_{xy}^m \sin 2\theta \) and \( \gamma_\Sigma^m = \gamma_{xy}^m \cos 2\theta - (\varepsilon_{xx}^m - \varepsilon_{yy}^m) \sin 2\theta \) depend on \( \theta \). These give the non-vanishing coefficients of the Fourier series of the misfit strains as \( \varepsilon_\Sigma^m = \frac{1}{2} (\varepsilon_{xx}^m + \varepsilon_{yy}^m), \varepsilon_\Sigma^A = \frac{1}{2} \gamma_{xy}^m \) and \( \gamma_\Sigma^m = \frac{1}{2} \gamma_{xy}^m \). Eqs. (24)-(28) give the system curvatures, which can be transformed to curvatures in the Cartesian coordinates as

\[
\kappa_{xx} + \kappa_{yy} = -\frac{E_h}{1-v_f} \left( \varepsilon_{xx}^m + \varepsilon_{yy}^m \right)
\]

(32)

which are also constant curvatures. The thin-film stresses in the Cartesian coordinates can be obtained from Eqs. (29)-(31) as

\[
\sigma_{xx}^{(f)} + \sigma_{yy}^{(f)} = -\frac{E_f}{1-v_f} \left( \varepsilon_{xx}^m + \varepsilon_{yy}^m \right)
\]

(33)

which are constant stresses in the thin film. Elimination of misfit strains from Eqs. (32) and (33) gives the relation between thin film stresses and system curvatures

\[
\sigma_{xx}^{(f)} + \sigma_{yy}^{(f)} = \frac{E_f h_f^2}{6(1-v_f) h_f} (\kappa_{xx} + \kappa_{yy})
\]

(34)

which is identical to Freund and Suresh (2004).
5.2 Axisymmetric normal misfit strains

We consider the axisymmetric normal misfit strains $\epsilon_m^m = \epsilon_{rr}^m(r), \epsilon_m^{\theta\theta} = \epsilon_{\theta\theta}^m(r)$ and $\gamma_m^{r\theta} = 0$, which give $\epsilon_\Sigma^m = \frac{1}{2}[\epsilon_{rr}^m(r)+\epsilon_{\theta\theta}^m(r)]$ and $\epsilon_\Delta^m = \frac{1}{2}[\epsilon_{rr}^m(r)-\epsilon_{\theta\theta}^m(r)]$. The non-vanishing displacement in the substrate is

$$u_r^{(r)} = \frac{E_f h_f}{1-\nu_f} \left[ \frac{1+\nu_f}{r} \int_0^1 \eta \epsilon_\Sigma^m d\eta + (1-\nu_f) r \int_0^1 \eta \epsilon_\Delta^m d\eta + \frac{1}{1+\nu_f} R^2 \int_0^1 \eta \epsilon_\Sigma^m d\eta \right]$$  \hspace{1cm} (35)

The normal displacement is given by

$$\frac{d\nu}{dr} = \frac{E_f h_f}{1-\nu_f} \left[ \frac{1+\nu_f}{r} \int_0^1 \eta \epsilon_\Sigma^m d\eta + (1-\nu_f) r \int_0^1 \eta \epsilon_\Delta^m d\eta + \frac{1}{1+\nu_f} R^2 \int_0^1 \eta \epsilon_\Sigma^m d\eta \right]$$  \hspace{1cm} (36)

which gives the non-vanishing system curvatures as

$$\kappa_r + \kappa_{\theta\theta} = -6 \frac{E_f h_f}{1-\nu_f} \left[ \frac{1+\nu_f}{r} \int_0^1 \eta \epsilon_\Sigma^m d\eta + (1-\nu_f) r \int_0^1 \eta \epsilon_\Delta^m d\eta + \frac{1}{1+\nu_f} R^2 \int_0^1 \eta \epsilon_\Sigma^m d\eta \right]$$  \hspace{1cm} (37)

$$\kappa_r - \kappa_{\theta\theta} = -6 \frac{E_f h_f}{1-\nu_f} \left[ \frac{1+\nu_f}{r} \int_0^1 \eta \epsilon_\Sigma^m d\eta + (1-\nu_f) r \int_0^1 \eta \epsilon_\Delta^m d\eta + \frac{1}{1+\nu_f} R^2 \int_0^1 \eta \epsilon_\Sigma^m d\eta \right]$$

The non-zero stresses in the thin film are $\sigma_{rr}^{(f)} + \sigma_{\theta\theta}^{(f)} = \frac{E_f}{1-\nu_f}(-2\epsilon_\Sigma^m)$ and $\sigma_{rr}^{(f)} - \sigma_{\theta\theta}^{(f)} = \frac{E_f}{1+\nu_f}(-2\epsilon_\Delta^m)$. Eq. (37) seems to provide two equations to determine $\epsilon_\Sigma^m$ and $\epsilon_\Delta^m$ (and therefore the thin-film stresses) in terms of curvatures. However, these two equations are NOT independent, as to be shown in the following.

The average curvature sum over the entire thin film $\overline{\kappa_r + \kappa_{\theta\theta}} = \frac{1}{R^2} \int_0^R \eta(\kappa_r + \kappa_{\theta\theta}) d\eta$ can be obtained from Eq. (37) as

$$\overline{\kappa_r + \kappa_{\theta\theta}} = -12 \frac{E_f h_f}{1-\nu_f} \overline{\epsilon_\Sigma^m} \left[ \frac{1+\nu_f}{r} \int_0^1 \eta \epsilon_\Sigma^m d\eta + (1-\nu_f) r \int_0^1 \eta \epsilon_\Delta^m d\eta + \frac{1}{1+\nu_f} R^2 \int_0^1 \eta \epsilon_\Sigma^m d\eta \right]$$  \hspace{1cm} (38)

where $\overline{\epsilon_\Sigma^m}$ and $\overline{\sigma_{rr}^{(f)} + \sigma_{\theta\theta}^{(f)}}$ are the average of $\epsilon_\Sigma^m$ and $\sigma_{rr}^{(f)} + \sigma_{\theta\theta}^{(f)}$, respectively. It is clear that $\overline{\sigma_{rr}^{(f)} + \sigma_{\theta\theta}^{(f)}}$ and $\overline{\kappa_r + \kappa_{\theta\theta}}$ satisfy the Stoney formula. The subtraction of Eq. (38) from Eq. (37) yields
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It can be shown that, if the misfit strains satisfy \( \kappa_{rr} - \kappa_{\theta\theta} = 0 \), the right sides of both Eq. (39) vanish. The curvatures then become uniform and equi-biaxial, \( \kappa_{rr} = \kappa_{\theta\theta} = -6 \frac{E_f h_f (1-v_f)}{E_s h_s (1-v_s)} \), but the stresses are still non-uniform and non-equibiaxial given by \( \sigma_{rr}^{(f)} = \frac{E_f}{1-v_f} \left( \frac{2}{r^2} \int_0^r \eta \varepsilon_m \, d\eta \right) \) and \( \sigma_{\theta\theta}^{(f)} = \frac{E_f}{1-v_f} \left( -2 \varepsilon_m + \frac{2}{r^2} \int_0^r \eta \varepsilon_m \, d\eta \right) \). Therefore, for axisymmetric misfit strains, the thin-film stresses may not be expressed in terms of the system curvatures. This point will become clearer in the next section 35.

5.3 Axisymmetric shear misfit strain

We consider the axisymmetric shear misfit strain \( \varepsilon_m = \varepsilon_m = 0 \) and \( \gamma_m = \gamma_m (r) \). The substrate displacement in the radial direction vanishes, \( u_r^{(s)} = 0 \), and that in the circumferential direction is given by

\[
u_r^{(s)}(r) = \frac{E_f h_f (1-v_f)}{1-v_f E_s h_s} \int_0^r \frac{\varepsilon_m}{R^2} \eta \, d\eta
\]

The normal displacement also vanishes \( w = 0 \), which gives vanishing system curvatures

\[
\kappa_{rr} = \kappa_{\theta\theta} = \kappa_{r\theta} = 0
\]

The normal stresses in the thin film are also zero, but the shear stress does not vanish

\[
\sigma_{rr}^{(f)} = \sigma_{\theta\theta}^{(f)} = 0, \quad \sigma_{r\theta}^{(f)} = \frac{E_f}{2(1+v_f)} \gamma_m
\]

It is clear that, for axisymmetric shear misfit strain, the non-vanishing thin-film stresses cannot be expressed in terms of the vanishing curvatures.

6. Extension of Stoney formula for nonuniform anisotropic misfit strains

Freund and Suresh (2004) obtained the anisotropic relation between thin film stresses and system...
curvatures for uniform misfit strains. In this section we extend it to nonuniform, linearly distributed misfit strains, i.e.,

$$
\begin{bmatrix}
\bar{\epsilon}_{xx}^m \\
\bar{\epsilon}_{xy}^m \\
\bar{\epsilon}_{yy}^m 
\end{bmatrix} =
\begin{bmatrix}
\bar{\epsilon}_{xx}^m \\
\bar{\epsilon}_{xy}^m \\
\bar{\epsilon}_{yy}^m 
\end{bmatrix} (1 + ax + by)
$$

(43)

where $a$ and $b$ are constants, and $ar{\epsilon}_{ij}^m$ are the average misfit strains, which can be related to the average system curvatures by

$$
\begin{bmatrix}
\bar{\kappa}_{xx} + \bar{\kappa}_{yy} \\
\bar{\kappa}_{xx} - \bar{\kappa}_{yy} \\
\bar{\kappa}_{yy}
\end{bmatrix} =
\begin{bmatrix}
-6 E f h_f \frac{1-v_f}{1+v_f} \frac{\bar{\epsilon}_{xx}^m + \bar{\epsilon}_{yy}^m}{H_f^2} \\
-6 E f h_f \frac{1-v_f}{1+v_f} \frac{\bar{\epsilon}_{xx}^m - \bar{\epsilon}_{yy}^m}{H_f^2} \\
0
\end{bmatrix}
$$

(44)

The constants $a$ and $b$ in Eq. (43) can be obtained by averaging $x(\kappa_{xx} + \kappa_{yy})$ and $y(\kappa_{xx} + \kappa_{yy})$ over the entire thin film as

$$
a = \frac{2(3+v_s)}{R^2} \frac{1}{[1+(1-v_s)\kappa_{xx}^m + \kappa_{yy}^m]^2 - [\frac{1-v_s}{2}(\kappa_{xx}^m - \kappa_{yy}^m)]^2 - [(1-v_s)\kappa_{xx}^m]^2} \times
$$

$$
\left\{ \frac{(1-v_f)\kappa_{xx}^m + (1-v_f)\kappa_{yy}^m}{2} \right\} \times \left\{ \frac{(1-v_s)\kappa_{xx}^m - (1-v_s)\kappa_{yy}^m}{2} \right\} \times
$$

$$
\left\{ \frac{(1+v_s)\kappa_{xx}^m + (1+v_s)\kappa_{yy}^m}{2} \right\} \times \left\{ \frac{(1+v_s)\kappa_{xx}^m - (1+v_s)\kappa_{yy}^m}{2} \right\} \times
$$

$$
\left\{ \frac{(1+v_f)\kappa_{xx}^m + (1+v_f)\kappa_{yy}^m}{2} \right\} \times \left\{ \frac{(1-v_f)\kappa_{xx}^m + (1-v_f)\kappa_{yy}^m}{2} \right\} \times
$$

$$
\left\{ \frac{(1-v_f)\kappa_{xx}^m - (1-v_f)\kappa_{yy}^m}{2} \right\} \times \left\{ \frac{(1+v_f)\kappa_{xx}^m - (1+v_f)\kappa_{yy}^m}{2} \right\}
$$

(45)

where $\bar{x}(\kappa_{xx}^m + \kappa_{yy}^m)$ and $\bar{y}(\kappa_{xx}^m + \kappa_{yy}^m)$ are the average of $x(\kappa_{xx} + \kappa_{yy})$ and $y(\kappa_{xx} + \kappa_{yy})$, respectively.

The thin-film stresses in the Cartesian coordinates can be obtained from Eqs. (29)-(31) as

$$
\begin{bmatrix}
\sigma_{xx}^{(f)} \\
\sigma_{xy}^{(f)} \\
\sigma_{yy}^{(f)}
\end{bmatrix} =
\begin{bmatrix}
\sigma_{xx}^{(f)} \\
\sigma_{xy}^{(f)} \\
\sigma_{yy}^{(f)}
\end{bmatrix} =
\begin{bmatrix}
E_f h_f \frac{1-v_f}{1+v_f} \frac{\bar{\epsilon}_{xx}^m + \bar{\epsilon}_{yy}^m}{H_f^2} \\
E_f h_f \frac{1-v_f}{1+v_f} \frac{\bar{\epsilon}_{xx}^m - \bar{\epsilon}_{yy}^m}{H_f^2} \\
0
\end{bmatrix}
$$

(46)

Elimination of misfit strains from Eqs. (44) and (46) gives the relation between thin film stresses and system curvatures.
Anisotropic, non-uniform misfit strain in a thin film bonded on a plate substrate

7. Concluding remarks and discussion

The stresses and curvatures are given in terms of anisotropic misfit strains in Section 4. For uniform misfit strains in Cartesian coordinates, the direct relation (34) between the thin-film stresses and system curvatures is established, and it is identical to Freund and Suresh (2004). However, for axisymmetric normal and shear misfit strains in Sections 34 and 35, such a film stress-curvature relation cannot be established because some components of anisotropic misfit strains give vanishing system curvatures but non-vanishing film stresses. This observation of no direct relation between film stresses and system curvatures also holds for non-uniform, anisotropic misfit strains. It is somewhat puzzling why a direction relation can be established for uniform, anisotropic misfit strains (in Cartesian coordinates) as in Eq. (34) but not for non-uniform misfit strains.

The average curvatures in Cartesian coordinates provide an explanation. The average curvature sum over the entire thin film in Eq. (38) can be rewritten in terms of the Cartesian components as

\[
\frac{\kappa_{xx} + \kappa_{yy}}{2} = -\frac{E_f h_f}{1 + \nu_f} \left( \frac{\kappa_{xx}^{m} + \kappa_{yy}^{m}}{2} \right) = -\frac{E_f h_f}{1 + \nu_f} \left( \frac{\kappa_{xx}^{m}}{2} + \frac{\kappa_{yy}^{m}}{2} \right)
\]  

(48)

The curvature components \(\kappa_{xx} - \kappa_{yy}\) and \(\kappa_{yy}\) in Cartesian coordinates can be obtained from \(\kappa_{r} - \kappa_{\theta}\) and \(\kappa_{\theta}\) in Eqs. (27) and (28), and their average over the entire thin film gives

\[
\left\{ \frac{\kappa_{xx} - \kappa_{yy}}{\kappa_{yy}} \right\} = -\frac{E_f h_f}{1 + \nu_f} \left( \frac{\kappa_{xx}^{m} - \kappa_{yy}^{m}}{2} \right)
\]  

(49)

Eqs. (43) and (44) suggest that the average misfit strains (and average film stresses) can be linked directly to the average curvatures. In fact, they become identical to Eq. (32) if the average misfit strains are replaced by uniform misfit strains.

The subtraction of curvatures by their averages gives \(\kappa_{xx} + \kappa_{yy} - \kappa_{xx} - \kappa_{yy}\), \(\kappa_{xx} - \kappa_{yy} - \kappa_{xx} + \kappa_{yy}\) and \(\kappa_{xy} - \kappa_{xy}\) in terms of \(\epsilon_{xx}^{m} + \epsilon_{yy}^{m} - \epsilon_{xx}^{m} + \epsilon_{yy}^{m}\), \(\epsilon_{xx}^{m} - \epsilon_{yy}^{m} - \epsilon_{xx}^{m} - \epsilon_{yy}^{m}\) and \(\epsilon_{xy}^{m} - \epsilon_{xy}^{m}\). However, these relations cannot be inverted to express the misfit strain deviation \(\epsilon_{a\beta}^{m} - \epsilon_{a\beta}^{m}\) in terms of the curvature deviation \(\kappa_{a\beta} - \kappa_{a\beta}\). This is because all curvatures are related to the same displacement \(u\) such that their derivatives are not independent. For example, for axisymmetric misfit strains in Section 34, the derivatives of curvatures satisfy

\[
\frac{d}{dr} \left[ r^2 (\kappa_{rr} - \kappa_{\theta\theta}) \right] = r^2 \frac{d}{dr} (\kappa_{rr} + \kappa_{\theta\theta})
\]

This relation becomes trivial for uniform curvatures. For non-uniform curvatures, however, it indicates that the derivatives of curvatures, or equivalently the curvature deviation \(\kappa_{a\beta} - \kappa_{a\beta}\), are not independent. This is the reason that the misfit strain deviation \(\epsilon_{a\beta}^{m} - \epsilon_{a\beta}^{m}\) cannot be solved from the curvature deviation \(\kappa_{a\beta} - \kappa_{a\beta}\).
However, for linear misfit strain distributions, the direct relation between the thin film stresses and system curvatures can be established. The interface shear stresses are related to the gradient of misfit strains via Eq. (14), and cannot be given in terms of curvatures directly.

References


